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Micro/Nano Manufacturing Processes: Theories and Optimization Techniques

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Deadline for manuscript submissions: **31 May 2024**

Message from the Guest Editors

This Special Issue aims to study some essential issues about theories and optimization techniques in the micro/nano manufacturing processes. Original research articles and reviews are welcome. Research areas may include (but are not limited to) the following:

- Micro/nano manufacturing technologies such as ultraprecision machining, photolithography, etching, ion beam machining, microforming, micromolding, etc.
- Theories and simulation analyses of micro/nano manufacturing;
- Molecular dynamic simulation of nano manufacturing;
- Optimization methods of micro/nano manufacturing processes;
- Size effects in micro/nano manufacturing;
- Micro/nano additive manufacturing;
- Non-conventional micro machining processes;
- Fabrication technologies and applications of nanomaterials;
- Applications of micro/nano components or systems.





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Message from the Editor-in-Chief

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